Surface Science 218 (1989) 603–606
North-Holland, Amsterdam

AUTHOR INDEX

Ala-Nissila, T., see Kjoll	218 (1989)	L476
Albert, M., see Lu	218 (1989)	1
Anderson, A.B., see Awad	218 (1989)	543
Andresen, P., see Ferm	218 (1989)	467
Awad, M.K. and A.B. Anderson, Methane activation by hole sites on AlN: a molecular orbital study	218 (1989)	543
Barnes, C.J., see Lindroos	218 (1989)	269
Bauer, K., see Vancea	218 (1989)	108
Behm, R.J., see Reynolds	218 (1989)	452
Bernasek, S.L., see Lu	218 (1989)	1
Buck, T.M., see Patterson	218 (1989)	431
Budde, F., see Ferm	218 (1989)	467
Chambers, G.P. and B.D. Sartwell, Growth modes of Ag deposited on Si(111) with simultaneous low energy ion bombardment	218 (1989)	55
Choyke, W.J., see Dresser	218 (1989)	75
Cocco, R.A. and B.J. Tatarchuk, Thiophene adsorption and decomposition on clean and sulfur precovered Ru(0001)	218 (1989)	127
Cocco, R.A. and B.J. Tatarchuk, Secondary ion formation mechanisms for thiophene on clean and sulfur precovered Ru(0001)	218 (1989)	147
Cocco, R.A., C. Papageorgopoulos and B.J. Tatarchuk, Static SIMS measurements during explosive desorption: desorption-induced recombination and cationization	218 (1989)	167
Collart, E. and R.J. Visser, Deep surface damage of SiO_2 by sputtering with low energy Ar-ions	218 (1989)	L497
Cortes, J., Distribution of adsorption energy and the effect of surface heterogeneity on the vibrational motion of adsorption	218 (1989)	L461
Craig, B.I. and P.V. Smith, SLAB–MINDO calculations on the Si(100) surface	218 (1989)	569
Dabringhaus, H. and H.J. Meyer, Interaction of molecular beams of RbCl with (100) surfaces of NaCl	218 (1989)	519
Davis, J.L., see Leavitt	218 (1989)	346
De Segovia, J.L., see Kurtz	218 (1989)	178
Diekmann, W., G. Panzner and H.J. Grabke, The bonding state of nitrogen segregated on Fe(100) and on iron nitrides Fe_4N and Fe_2N	218 (1989)	507
Dolbak, A.E., B.Z. Olshanetsky, S.I. Stenin, S.A. Teys and T.A. Gavrilova, Effect of nickel on clean silicon surfaces: transport and structure	218 (1989)	37
Dresser, M.J., P.A. Taylor, R.M. Wallace, W.J. Choyke and J.T. Yates, Jr., The adsorption and decomposition of NH_3 on Si(100) – detection of the NH_2(a) species	218 (1989)	75

Dwyer, D.S., see Lu 218 (1989) 1
Dyer, J.S., see Leavitt 218 (1989) 346

Eridon, J.M., see Gilmore 218 (1989) 26
Erley, W. and B.N.J. Persson, Vibrational lineshapes for NO on Ni(111) 218 (1989) 494
Ertl, G., see Reynolds 218 (1989) 452

Ferm, P.M., F. Budde, A.V. Hamza, S. Jakubith, D. Weide, P. Andresen and H.J. Freund, UV-laser-induced photodesorption of NO from NiO 218 (1989) 467
Freund, H.J., see Ferm 218 (1989) 467
Fujisawa, H., see Ikezawa 218 (1989) 246

Galán, L., see Morant 218 (1989) 331
Gavrilova, T.A., see Dolbak 218 (1989) 37
Gilmore, C.M., J.A. Sprague, J.M. Eridon and V. Provenzano, An embedded atom analysis of Au clusters on a Ni surface 218 (1989) 26
Gomer, R., see Lin 218 (1989) 406
Goodman, D.W., see He 218 (1989) 211
Grabke, H.J., see Diekmann 218 (1989) 507

Hamza, A.V., see Ferm 218 (1989) 467
He, J.-W. and D.W. Goodman, Nitrogen adsorption on Re(0001) studied by LEED, TPD, AES and ELS 218 (1989) 211
Hoffmann, H., see Vancea 218 (1989) 108
Hu, Z.P., J. Li, N.J. Wu and A. Ignatiev, C(0001)-($\sqrt{3} \times \sqrt{3}$)R30°-Cs structure determination: *R*-factor analysis 218 (1989) 283
Huber, W., see Steinrück 218 (1989) 293

Ignatiev, A., see Hu 218 (1989) 283
Ikezawa, Y., H. Fujisawa and F. Ishii, IR active and inactive CO adsorbed on a Pt electrode in acidic solution observed by reflection absorption spectroscopy 218 (1989) 246
Ishii, F., see Ikezawa 218 (1989) 246
Ishitani, T., K. Umemura and Y. Kawanami, Observation of doubly-charged dimer ion emission in liquid-metal-ion sources 218 (1989) 259

Jakubith, S., see Ferm 218 (1989) 467

Kaletta, D., see Reynolds 218 (1989) 452
Kawanami, Y., see Ishitani 218 (1989) 259
King, D.A., see Lindroos 218 (1989) 269
Kjoll, J., T. Ala-Nissila and S.C. Ying, Diffusion anisotropy of oxygen and hydrogen adatoms on W(110) 218 (1989) L476
Koel, B.E., see Zhou 218 (1989) 201
Kurtz, R.L., R. Stockbauer, T.E. Madey, E. Román and J.L. De Segovia, Synchrotron radiation studies of H_2O adsorption on TiO_2(110) 218 (1989) 178

Leavitt, P.K., J.L. Davis, J.S. Dyer and P.A. Thiel, Adsorption of water on Ru(100) 218 (1989) 346
Levi, A.C. and M. Touzani, The Au(110) surface described by interacting 6-vertex models 218 (1989) 223

Li, J., see Hu 218 (1989) 283
Lin, J.C. and R. Gomer, Electron stimulated desorption from CO and O adsorbed on clean and Cu covered W(110) surfaces 218 (1989) 406
Lindroos, M., C.J. Barnes, M. Valden and D.A. King, A re-examination of multilayer relaxation of Ag(110) by LEED structural analysis 218 (1989) 269
Lloyd, D.R., see Ramsey 218 (1989) 317
Lu, J.-P., M. Albert, S.L. Bernasek and D.S. Dwyer, Decomposition of methanol on oxygen-modified Fe(100) surfaces. I. The effect of high temperature oxygen modification 218 (1989) 1

Madey, T.E., see Kurtz 218 (1989) 178
Marton, D., see Unger 218 (1989) L467
Menzel, D., see Steinrück 218 (1989) 293
Meyer, H.J., see Dabringhaus 218 (1989) 519
Milun, M., P. Pervan and K. Wandelt, Interaction of oxygen with a polycrystalline palladium surface over a wide temperature range 218 (1989) 363
Mišković, Z.L. and J.V. Vukanić, A semiclassical treatment of ion dynamics in electron stimulated desorption 218 (1989) 389
Morant, C., J.M. Sanz, L. Galán, L. Soriano and F. Rueda, An XPS study of the interaction of oxygen with zirconium 218 (1989) 331

Netzer, F.P., see Ramsey 218 (1989) 317
Nicholls, J.M. and B. Reihl, Antibonding surface state band of the Ge(111)-2 × 1 surface 218 (1989) 237

Olshanetsky, B.Z., see Dolbak 218 (1989) 37

Pache, T., see Steinrück 218 (1989) 293
Panzner, G., see Diekmann 218 (1989) 507
Papageorgopoulos, C., see Cocco 218 (1989) 167
Patterson, C.H. and T.M. Buck, The binding site of CO on NiAl(110) determined by low energy ion scattering 218 (1989) 431
Persson, B.N.J., see Erley 218 (1989) 494
Pervan, P., see Milun 218 (1989) 363
Provenzano, V., see Gilmore 218 (1989) 26

Ramsey, M.G., G. Rosina, F.P. Netzer, H.B. Saalfeld and D.R. Lloyd, Adsorption of CN on Pd(110): a study with angle-resolved ultraviolet photoelectron spectroscopy and LEED 218 (1989) 317
Reihl, B., see Nicholls 218 (1989) 237
Reiss, G., see Vancea 218 (1989) 108
Reynolds, A.E., D. Kaletta, G. Ertl and R.J. Behm, Computer simulations of the adsorbate-induced structural transformation of Pt(100) 218 (1989) 452
Román, E., see Kurtz 218 (1989) 178
Rosenberg, R.A., see Wen 218 (1989) L483
Rosina, G., see Ramsey 218 (1989) 317
Rueda, F., see Morant 218 (1989) 331

Saalfeld, H.B., see Ramsey 218 (1989) 317
Sanz, J.M., see Morant 218 (1989) 331
Sartwell, B.D., see Chambers 218 (1989) 55
Sasse, A.G.B.M., H. Wormeester, M.A. van der Hoef and A. van Silfhout, Transition density of states (TDOS) of the Si(100)2 × 1 surface derived from the $L_{2,3}VV$ Auger lineshape compared with cluster calculations 218 (1989) 553

Schaich, W.L., see Shen 218 (1989) 580
Schneider, F., see Vancea 218 (1989) 108
Selmani, A., Ethylene oxide on Fe(100) and Ni(111) surfaces. Molecular orbital study 218 (1989) 19
Shen, W. and W.L. Schaich, The optical effects of an adsorbate layer: *d*-parameter description of simple models 218 (1989) 580
Smith, P.V., see Craig 218 (1989) 569
Soriano, L., see Morant 218 (1989) 331
Sprague, J.A., see Gilmore 218 (1989) 26
Steinrück, H.-P., W. Huber, T. Pache and D. Menzel, The adsorption of benzene mono- and multilayers on Ni(111) studied by TPD and LEED 218 (1989) 293
Stenin, S.I., see Dolbak 218 (1989) 37
Stockbauer, R., see Kurtz 218 (1989) 178
Suětaka, W., see Wadayama 218 (1989) L490

Tatarchuk, B.J., see Cocco 218 (1989) 127
Tatarchuk, B.J., see Cocco 218 (1989) 147
Tatarchuk, B.J., see Cocco 218 (1989) 167
Taylor, P.A., see Dresser 218 (1989) 75
Teys, S.A., see Dolbak 218 (1989) 37
Thiel, P.A., see Leavitt 218 (1989) 346
Touzani, M., see Levi 218 (1989) 223

Umemura, K., see Ishitani 218 (1989) 259
Unger, W. and D. Marton, A SIMS and XPS examination of low-pressure oxygen adsorption on Pt_3Sn. Oxygen uptake and surface characteristics 218 (1989) L467

Valden, M., see Lindroos 218 (1989) 269
Van der Hoef, M.A., see Sasse 218 (1989) 553
Van Silfhout, A., see Sasse 218 (1989) 553
Vancea, J., G. Reiss, F. Schneider, K. Bauer and H. Hoffmann, Substrate effects on the surface topography of evaporated gold films – a scanning tunnelling microscopy investigation 218 (1989) 108
Visser, R.J., see Collart 218 (1989) L497
Vukanić, J.V., see Mišković 218 (1989) 389

Wadayama, T. and W. Suětaka, Metastable surface layer of a silicon nitride thin film growing by photo-chemical vapor deposition 218 (1989) L490
Wallace, R.M., see Dresser 218 (1989) 75
Wandelt, K., see Milun 218 (1989) 363
Weide, D., see Ferm 218 (1989) 467
Wen, C.-R. and R.A. Rosenberg, Time-dependent photolysis of adsorbed molecules using synchrotron radiation: $CH_3F/Si(111)(7 \times 7)$ 218 (1989) L483
White, J.M., see Zhou 218 (1989) 201
Wormeester, H., see Sasse 218 (1989) 553
Wu, N.J., see Hu 218 (1989) 283

Yates, Jr., J.T., see Dresser 218 (1989) 75
Ying, S.C., see Kjoll 218 (1989) L476

Zhou, X.-L., J.M. White and B.E. Koel, Chemisorption of atomic hydrogen on clean and Cl-covered Ag(111) 218 (1989) 201

Surface Science 218 (1989) 607–618
North-Holland, Amsterdam

SUBJECT INDEX

Alkali halides

J. Cortes, Distribution of adsorption energy and the effect of surface heterogeneity on the vibrational motion of adsorption 218 (1989) L461
H. Dabringhaus and H.J. Meyer, Interaction of molecular beams of RbCl with (100) surfaces of NaCl 218 (1989) 519

Alkali metals

Z.P. Hu, J. Li, N.J. Wu and A. Ignatiev, C(0001)-($\sqrt{3} \times \sqrt{3}$)R30°-Cs structure determination: *R*-factor analysis 218 (1989) 283

Alloys

W. Unger and D. Marton, A SIMS and XPS examination of low-pressure oxygen adsorption on Pt_3Sn. Oxygen uptake and surface characteristics 218 (1989) L467
C.H. Patterson and T.M. Buck, The binding site of CO on NiAl(110) determined by low energy ion scattering 218 (1989) 431

Ammonia

M.J. Dresser, P.A. Taylor, R.M. Wallace, W.J. Choyke and J.T. Yates, Jr., The adsorption and decomposition of NH_3 on Si(100) – detection of the NH_2(a) species 218 (1989) 75

Antimony

T. Ishitani, K. Umemura and Y. Kawanami, Observation of doubly-charged dimer ion emission in liquid-metal-ion sources 218 (1989) 259

Atomic and molecular beam studies

H. Dabringhaus and H.J. Meyer, Interaction of molecular beams of RbCl with (100) surfaces of NaCl 218 (1989) 519

Auger electron spectroscopy

A.E. Dolbak, B.Z. Olshanetsky, S.I. Stenin, S.A. Teys and T.A. Gavrilova, Effect of nickel on clean silicon surfaces: transport and structure 218 (1989) 37

A.G.B.M. Sasse, H. Wormeester, M.A. van der Hoef and A. van Silfhout, Transition density of states (TDOS) of the Si(100)2 × 1 surface derived from the $L_{2,3}VV$ Auger lineshape compared with cluster calculations 218 (1989) 553

Band structure

J.M. Nicholls and B. Reihl, Antibonding surface state band of the Ge(111)-2 × 1 surface 218 (1989) 237

Benzene

H.-P. Steinrück, W. Huber, T. Pache and D. Menzel, The adsorption of benzene mono- and multilayers on Ni(111) studied by TPD and LEED 218 (1989) 293

Carbon monoxide

Y. Ikezawa, H. Fujisawa and F. Ishii, IR active and inactive CO adsorbed on a Pt electrode in acidic solution observed by reflection absorption spectroscopy 218 (1989) 246
J.C. Lin and R. Gomer, Electron stimulated desorption from CO and O adsorbed on clean and Cu covered W(110) surfaces 218 (1989) 406
C.H. Patterson and T.M. Buck, The binding site of CO on NiAl(110) determined by low energy ion scattering 218 (1989) 431

Chemical vapour deposition

T. Wadayama and W. Suëtaka, Metastable surface layer of a silicon nitride thin film growing by photo-chemical vapor deposition 218 (1989) L490

Chemisorption theory

A. Selmani, Ethylene oxide on Fe(100) and Ni(111) surfaces. Molecular orbital study 218 (1989) 19
C.M. Gilmore, J.A. Sprague, J.M. Eridon and V. Provenzano, An embedded atom analysis of Au clusters on a Ni surface 218 (1989) 26
M.K. Awad and A.B. Anderson, Methane activation by hole sites on AlN: a molecular orbital study 218 (1989) 543
A.G.B.M. Sasse, H. Wormeester, M.A. van der Hoef and A. van Silfhout, Transition density of states (TDOS) of the Si(100)2 × 1 surface derived from the $L_{2,3}VV$ Auger lineshape compared with cluster calculations 218 (1989) 553

Clusters

C.M. Gilmore, J.A. Sprague, J.M. Eridon and V. Provenzano, An embedded atom analysis of Au clusters on a Ni surface 218 (1989) 26
T. Ishitani, K. Umemura and Y. Kawanami, Observation of doubly-charged dimer ion emission in liquid-metal-ion sources 218 (1989) 259

Copper

J.C. Lin and R. Gomer, Electron stimulated desorption from CO and O adsorbed on clean and Cu covered W(110) surfaces 218 (1989) 406

Cyanogen

M.G. Ramsey, G. Rosina, F.P. Netzer, H.B. Saalfeld and D.R. Lloyd, Adsorption of CN on Pd(110): a study with angle-resolved ultraviolet photoelectron spectroscopy and LEED 218 (1989) 317

Deuterium

X.-L. Zhou, J.M. White and B.E. Koel, Chemisorption of atomic hydrogen on clean and Cl-covered Ag(111) 218 (1989) 201

Dielectric constant

W. Shen and W.L. Schaich, The optical effects of an adsorbate layer: *d*-parameter description of simple models 218 (1989) 580

Electron emission

J.M. Nicholls and B. Reihl, Antibonding surface state band of the Ge(111)-2 × 1 surface 218 (1989) 237

Electron energy loss spectroscopy

J.-P. Lu, M. Albert, S.L. Bernasek and D.S. Dwyer, Decomposition of methanol on oxygen-modified Fe(100) surfaces. I. The effect of high temperature oxygen modification 218 (1989) 1

J.-W. He and D.W. Goodman, Nitrogen adsorption on Re(0001) studied by LEED, TPD, AES and ELS 218 (1989) 211

P.K. Leavitt, J.L. Davis, J.S. Dyer and P.A. Thiel, Adsorption of water on Ru(100) 218 (1989) 346

Electron microscopy

H. Dabringhaus and H.J. Meyer, Interaction of molecular beams of RbCl with (100) surfaces of NaCl 218 (1989) 519

Electron stimulated desorption

M.J. Dresser, P.A. Taylor, R.M. Wallace, W.J. Choyke and J.T. Yates, Jr., The adsorption and decomposition of NH_3 on Si(100) – detection of the NH_2(a) species 218 (1989) 75

Z.L. Mišković and J.V. Vukanić, A semiclassical treatment of ion dynamics in electron stimulated desorption 218 (1989) 389

J.C. Lin and R. Gomer, Electron stimulated desorption from CO and O adsorbed on clean and Cu covered W(110) surfaces 218 (1989) 406

Ellipsometry

W. Shen and W.L. Schaich, The optical effects of an adsorbate layer: *d*-parameter description of simple models 218 (1989) 580

Ethylene

A. Selmani, Ethylene oxide on Fe(100) and Ni(111) surfaces. Molecular orbital study 218 (1989) 19

Germanium

J.M. Nicholls and B. Reihl, Antibonding surface state band of the Ge(111)-2 × 1 surface 218 (1989) 237

Gold

C.M. Gilmore, J.A. Sprague, J.M. Eridon and V. Provenzano, An embedded atom analysis of Au clusters on a Ni surface 218 (1989) 26

J. Vancea, G. Reiss, F. Schneider, K. Bauer and H. Hoffmann, Substrate effects on the surface topography of evaporated gold films – a scanning tunnelling microscopy investigation 218 (1989) 108

A.C. Levi and M. Touzani, The Au(110) surface described by interacting 6-vertex models 218 (1989) 223

T. Ishitani, K. Umemura and Y. Kawanami, Observation of doubly-charged dimer ion emission in liquid-metal-ion sources 218 (1989) 259

Graphite

Z.P. Hu, J. Li, N.J. Wu and A. Ignatiev, C(0001)-($\sqrt{3} \times \sqrt{3}$)R30°-Cs structure determination: *R*-factor analysis 218 (1989) 283

Halogens

X.-L. Zhou, J.M. White and B.E. Koel, Chemisorption of atomic hydrogen on clean and Cl-covered Ag(111) 218 (1989) 201

Hydrogen

X.-L. Zhou, J.M. White and B.E. Koel, Chemisorption of atomic hydrogen on clean and Cl-covered Ag(111) 218 (1989) 201

J. Kjoll, T. Ala-Nissila and S.C. Ying, Diffusion anisotropy of oxygen and hydrogen adatoms on W(110) 218 (1989) L476

Infrared spectroscopy

Y. Ikezawa, H. Fujisawa and F. Ishii, IR active and inactive CO adsorbed on a Pt electrode in acidic solution observed by reflection absorption spectroscopy 218 (1989) 246
T. Wadayama and W. Suëtaka, Metastable surface layer of a silicon nitride thin film growing by photo-chemical vapor deposition 218 (1989) L490
W. Erley and B.N.J. Persson, Vibrational lineshapes for NO on Ni(111) 218 (1989) 494

Ion bombardment

G.P. Chambers and B.D. Sartwell, Growth modes of Ag deposited on Si(111) with simultaneous low energy ion bombardment 218 (1989) 55

Ion scattering

C.H. Patterson and T.M. Buck, The binding site of CO on NiAl(110) determined by low energy ion scattering 218 (1989) 431

Iron

J.-P. Lu, M. Albert, S.L. Bernasek and D.S. Dwyer, Decomposition of methanol on oxygen-modified Fe(100) surfaces. I. The effect of high temperature oxygen modification 218 (1989) 1
A. Selmani, Ethylene oxide on Fe(100) and Ni(111) surfaces. Molecular orbital study 218 (1989) 19
W. Diekmann, G. Panzner and H.J. Grabke, The bonding state of nitrogen segregated on Fe(100) and on iron nitrides Fe_4N and Fe_2N 218 (1989) 507

Low energy electron diffraction

A.E. Dolbak, B.Z. Olshanetsky, S.I. Stenin, S.A. Teys and T.A. Gavrilova, Effect of nickel on clean silicon surfaces: transport and structure 218 (1989) 37
J.-W. He and D.W. Goodman, Nitrogen adsorption on Re(0001) studied by LEED, TPD, AES and ELS 218 (1989) 211
M. Lindroos, C.J. Barnes, M. Valden and D.A. King, A re-examination of multilayer relaxation of Ag(110) by LEED structural analysis 218 (1989) 269
Z.P. Hu, J. Li, N.J. Wu and A. Ignatiev, C(0001)-$(\sqrt{3} \times \sqrt{3})$R30°-Cs structure determination: *R*-factor analysis 218 (1989) 283
H.-P. Steinrück, W. Huber, T. Pache and D. Menzel, The adsorption of benzene mono- and multilayers on Ni(111) studied by TPD and LEED 218 (1989) 293
M.G. Ramsey, G. Rosina, F.P. Netzer, H.B. Saalfeld and D.R. Lloyd, Adsorption of CN on Pd(110): a study with angle-resolved ultraviolet photoelectron spectroscopy and LEED 218 (1989) 317

Methane

M.K. Awad and A.B. Anderson, Methane activation by hole sites on AlN: a molecular orbital study 218 (1989) 543

Methanol

J.-P. Lu, M. Albert, S.L. Bernasek and D.S. Dwyer, Decomposition of methanol on oxygen-modified Fe(100) surfaces. I. The effect of high temperature oxygen modification 218 (1989) 1

Nickel

A. Selmani, Ethylene oxide on Fe(100) and Ni(111) surfaces. Molecular orbital study 218 (1989) 19
C.M. Gilmore, J.A. Sprague, J.M. Eridon and V. Provenzano, An embedded atom analysis of Au clusters on a Ni surface 218 (1989) 26
A.E. Dolbak, B.Z. Olshanetsky, S.I. Stenin, S.A. Teys and T.A. Gavrilova, Effect of nickel on clean silicon surfaces: transport and structure 218 (1989) 37
H.-P. Steinrück, W. Huber, T. Pache and D. Menzel, The adsorption of benzene mono- and multilayers on Ni(111) studied by TPD and LEED 218 (1989) 293
W. Erley and B.N.J. Persson, Vibrational lineshapes for NO on Ni(111) 218 (1989) 494

Nickel oxide

P.M. Ferm, F. Budde, A.V. Hamza, S. Jakubith, D. Weide, P. Andresen and H.J. Freund, UV-laser-induced photodesorption of NO from NiO 218 (1989) 467

Nitric oxide

P.M. Ferm, F. Budde, A.V. Hamza, S. Jakubith, D. Weide, P. Andresen and H.J. Freund, UV-laser-induced photodesorption of NO from NiO 218 (1989) 467
W. Erley and B.N.J. Persson, Vibrational lineshapes for NO on Ni(111) 218 (1989) 494

Nitrides

W. Diekmann, G. Panzner and H.J. Grabke, The bonding state of nitrogen segregated on Fe(100) and on iron nitrides Fe_4N and Fe_2N 218 (1989) 507
M.K. Awad and A.B. Anderson, Methane activation by hole sites on AlN: a molecular orbital study 218 (1989) 543

Nitrogen

J.-W. He and D.W. Goodman, Nitrogen adsorption on Re(0001) studied by LEED, TPD, AES and ELS 218 (1989) 211
W. Diekmann, G. Panzner and H.J. Grabke, The bonding state of nitrogen segregated on Fe(100) and on iron nitrides Fe_4N and Fe_2N 218 (1989) 507

Noble gases

J. Cortes, Distribution of adsorption energy and the effect of surface heterogeneity on the vibrational motion of adsorption 218 (1989) L461

Nucleation

G.P. Chambers and B.D. Sartwell, Growth modes of Ag deposited on Si(111) with simultaneous low energy ion bombardment 218 (1989) 55

Organic substances

R.A. Cocco and B.J. Tatarchuk, Thiophene adsorption and decomposition on clean and sulfur precovered Ru(0001) 218 (1989) 127
R.A. Cocco and B.J. Tatarchuk, Secondary ion formation mechanisms for thiophene on clean and sulfur precovered Ru(0001) 218 (1989) 147
R.A. Cocco, C. Papageorgopoulos and B.J. Tatarchuk, Static SIMS measurements during explosive desorption: desorption-induced recombination and cationization 218 (1989) 167
C.-R. Wen and R.A. Rosenberg, Time-dependent photolysis of adsorbed molecules using synchrotron radiation: $CH_3F/Si(111)(7 \times 7)$ 218 (1989) L483

Oxygen

J.-P. Lu, M. Albert, S.L. Bernasek and D.S. Dwyer, Decomposition of methanol on oxygen-modified Fe(100) surfaces. I. The effect of high temperature oxygen modification 218 (1989) 1
W. Unger and D. Marton, A SIMS and XPS examination of low-pressure oxygen adsorption on Pt_3Sn. Oxygen uptake and surface characteristics 218 (1989) L467
J. Kjoll, T. Ala-Nissila and S.C. Ying, Diffusion anisotropy of oxygen and hydrogen adatoms on W(110) 218 (1989) L476
C. Morant, J.M. Sanz, L. Galán, L. Soriano and F. Rueda, An XPS study of the interaction of oxygen with zirconium 218 (1989) 331
M. Milun, P. Pervan and K. Wandelt, Interaction of oxygen with a polycrystalline palladium surface over a wide temperature range 218 (1989) 363
J.C. Lin and R. Gomer, Electron stimulated desorption from CO and O adsorbed on clean and Cu covered W(110) surfaces 218 (1989) 406

Palladium

M.G. Ramsey, G. Rosina, F.P. Netzer, H.B. Saalfeld and D.R. Lloyd, Adsorption of CN on Pd(110): a study with angle-resolved ultraviolet photoelectron spectroscopy and LEED 218 (1989) 317
M. Milun, P. Pervan and K. Wandelt, Interaction of oxygen with a polycrystalline palladium surface over a wide temperature range 218 (1989) 363

Photodesorption

C.-R. Wen and R.A. Rosenberg, Time-dependent photolysis of adsorbed molecules using synchrotron radiation: $CH_3F/Si(111)(7 \times 7)$ 218 (1989) L483
P.M. Ferm, F. Budde, A.V. Hamza, S. Jakubith, D. Weide, P. Andresen and H.J. Freund, UV-laser-induced photodesorption of NO from NiO 218 (1989) 467

Photoelectron spectroscopy

R.L. Kurtz, R. Stockbauer, T.E. Madey, E. Román and J.L. De Segovia, Synchrotron radiation studies of H_2O adsorption on $TiO_2(110)$ 218 (1989) 178
X.-L. Zhou, J.M. White and B.E. Koel, Chemisorption of atomic hydrogen on clean and Cl-covered Ag(111) 218 (1989) 201
C.-R. Wen and R.A. Rosenberg, Time-dependent photolysis of adsorbed molecules using synchrotron radiation: $CH_3F/Si(111)(7 \times 7)$ 218 (1989) L483
M.G. Ramsey, G. Rosina, F.P. Netzer, H.B. Saalfeld and D.R. Lloyd, Adsorption of CN on Pd(110): a study with angle-resolved ultraviolet photoelectron spectroscopy and LEED 218 (1989) 317
C. Morant, J.M. Sanz, L. Galán, L. Soriano and F. Rueda, An XPS study of the interaction of oxygen with zirconium 218 (1989) 331
W. Diekmann, G. Panzner and H.J. Grabke, The bonding state of nitrogen segregated on Fe(100) and on iron nitrides Fe_4N and Fe_2N 218 (1989) 507

Platinum

Y. Ikezawa, H. Fujisawa and F. Ishii, IR active and inactive CO adsorbed on a Pt electrode in acidic solution observed by reflection absorption spectroscopy 218 (1989) 246
T. Ishitani, K. Umemura and Y. Kawanami, Observation of doubly-charged dimer ion emission in liquid-metal-ion sources 218 (1989) 259
A.E. Reynolds, D. Kaletta, G. Ertl and R.J. Behm, Computer simulations of the adsorbate-induced structural transformation of Pt(100) 218 (1989) 452

Rhenium

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Ruthenium

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Work function

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X-ray emission

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